

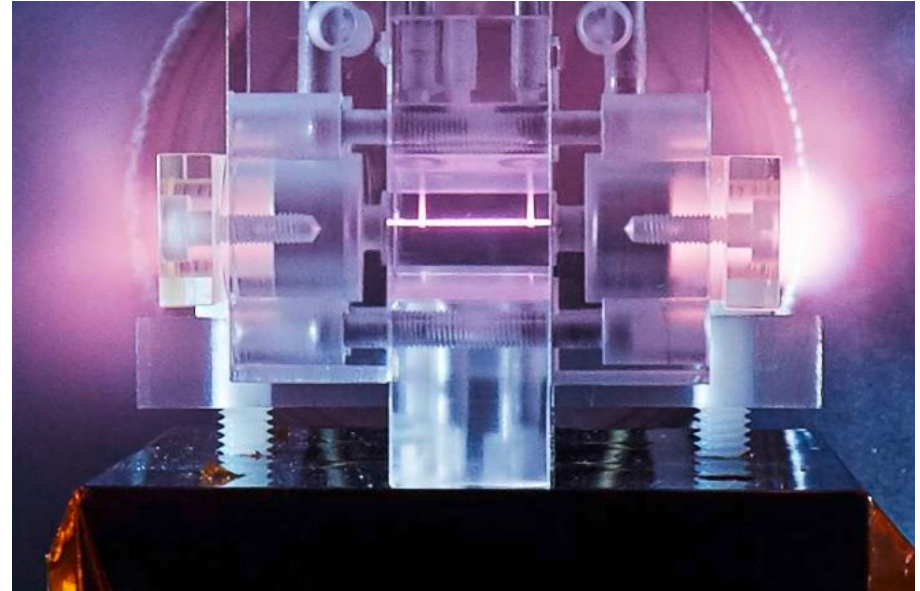
Mapping plasma lenses

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Motivation

- > Plasma accelerators create sub- μm emittance beams
- > Intrinsic energy spread σ_E of percent level
- > Divergence $\sigma_{x'}$ typically mrad
- > Emittance growth during drift $\rightarrow \epsilon_n \sim \sigma_E \cdot \sigma_{x'}^2 \cdot s$
- > Compact and strong capturing needed
- > APLs provide short focal length
- > Radially symmetric focusing



First experiments: Forsyth et al., *IEEE Trans. on Nucl. Sc.* 12.3 (1965): 872-876.

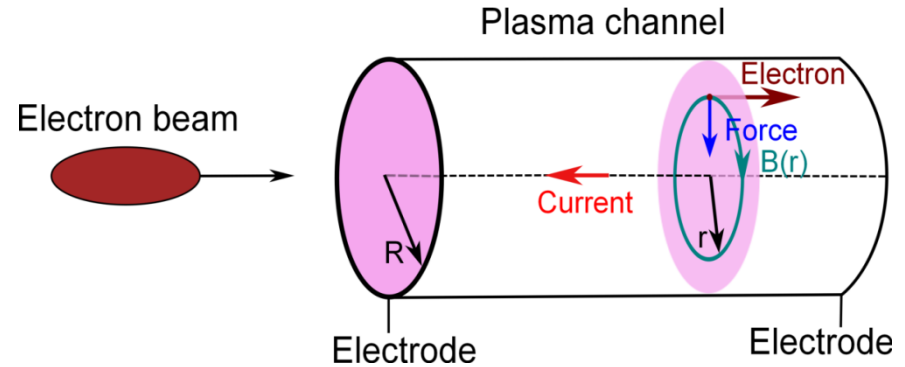
Target concept: Butler et al., *Phys. Rev. Lett.* 89.18 (2002): 185003.

First capillary lens: Van Tilborg, et al., *Phys. Rev. Lett.* 115.18 (2015): 184802.

Used in staging: Steinke et al., *Nature* 530.7589 (2016): 190.

Active plasma lens principle

- > Beam passes high current region
- > Radially symmetric magnetic field
- > Gradients of $\sim 3\text{kT/m}$ achieved¹
- > High voltage discharge ignites plasma
- > Gas volume required
- > Wakefields should be avoided



$$B_{\varphi}(r) = \frac{\mu_0 I_0}{2\pi} \cdot \frac{r}{R^2} \longrightarrow \frac{\partial B_{\varphi}}{\partial r} = 0.2 \frac{I[\text{A}]}{R[\text{mm}]^2} \frac{\text{T}}{\text{m}}$$

¹Van Tilborg, et al., *Phys. Rev. Lett.* 115.18 (2015): 184802.

Probing the quality of plasma lenses

- > Measure shot-to-shot stability
 - ▶ Assess gradient stability
 - ▶ Assess discharge stability
 - ▶ Stable electron beam needed
- > Probe for inhomogeneity
 - ▶ Gradient depends on current distribution
 - ▶ Inhomogeneity leads to nonlinear focusing
 - ▶ Emittance degradation in the plasma lens

$$B_{\varphi}(r) = \frac{\mu_0}{2} (a_1 + a_4 \cdot r^3)r$$

Magnetohydrodynamics simulation

To be published

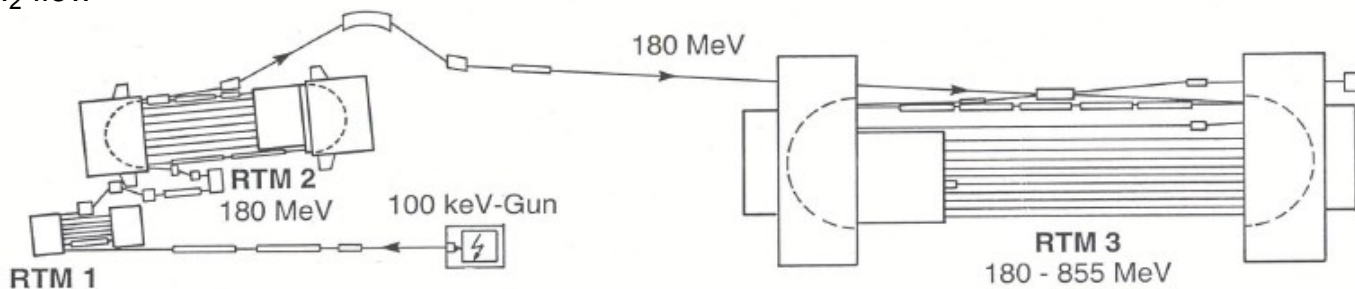
Courtesy of J. van Tilborg and S. Bulanov

The Mainz Microtron

> Racetrack Microtron

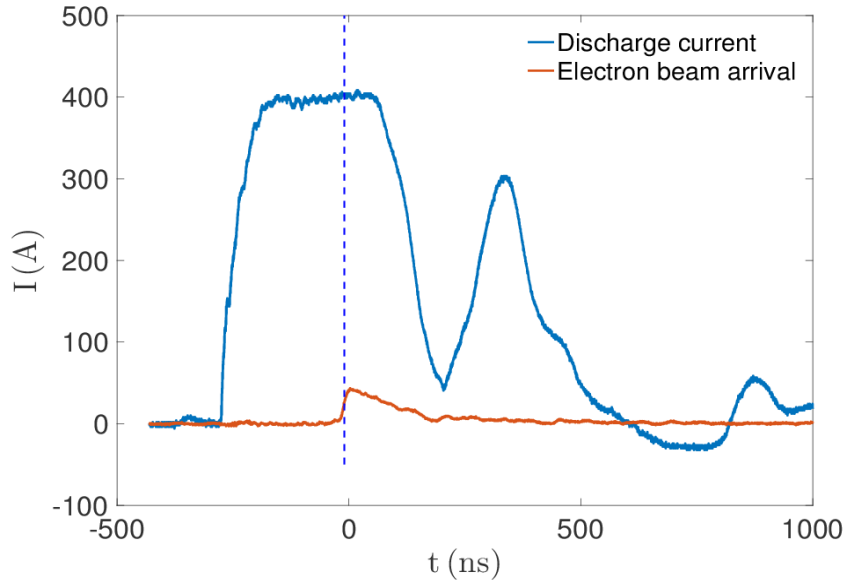
- ▶ $E = 855 \text{ MeV}$ with $\sigma_E = 4 \cdot 10^{-5}$
- ▶ Special operation mode with 10 ns bunch train
- ▶ Current $100 \mu\text{A}$ – no wakefields
- ▶ Norm. Emittance 1.5 mm mrad
- ▶ Transverse jitter $\sim 20\%$ of beam size

> Beamline allowing for H_2 flow



Discharge characteristics

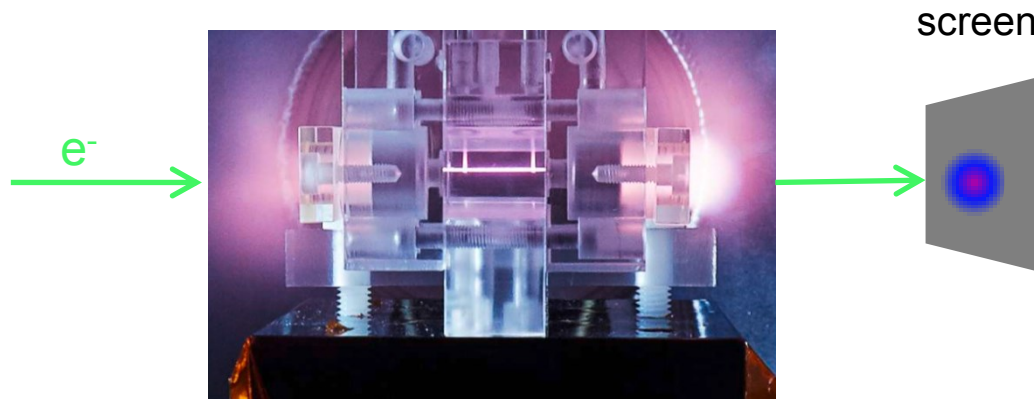
Current profile @20kV



- > Amplitude stability of 1.5 A rms
- > Plateau region of ~250 ns
- > Current plateau tunable up to 1.5 kA
- > Stable in timing: ~1 ns rms breakdown jitter
- > Electron beam arrival monitored
- > Single shot analysis possible

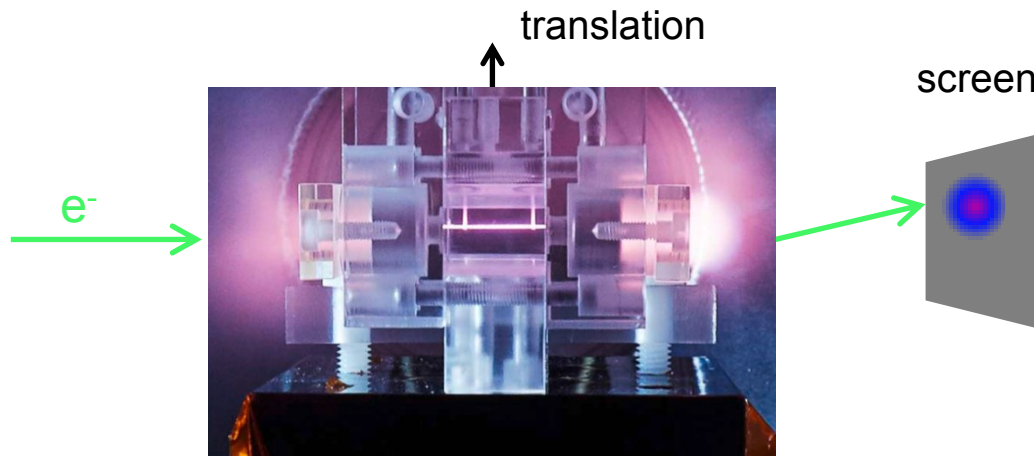
Lens position scan – gradient via dipole kick

- > Lens position varied transversally
- > Dipole kick introduced
- > Beam position on screen changes
- > Kick yields field – kicks yield gradient
- > Position stability → gradient stability



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Gradient measurement results

- > Scans using 7 mm long APL
- > Very low transverse jitter
- > Stable discharge and APL
 - ▶ 100 shots per scan point
 - ▶ No faulty discharges
- > Higher gradients than expected
 - ▶ 40% - 60% bigger than uniform density

Current [A]	Uniform [T/m]	Linear [T/m]	Polynomial [T/m]
188	150	246 ± 10	265 ± 35
368	294	437 ± 8	475 ± 30
740	592	823 ± 8	886 ± 38

To be published

$$I_0 = 2 \pi \int_0^R J(r) \cdot r dr \longrightarrow B_\varphi(R) = \frac{\mu_0 I_0}{2\pi R}$$

Emittance measurement - MaMi-B beamline

> Two chambers

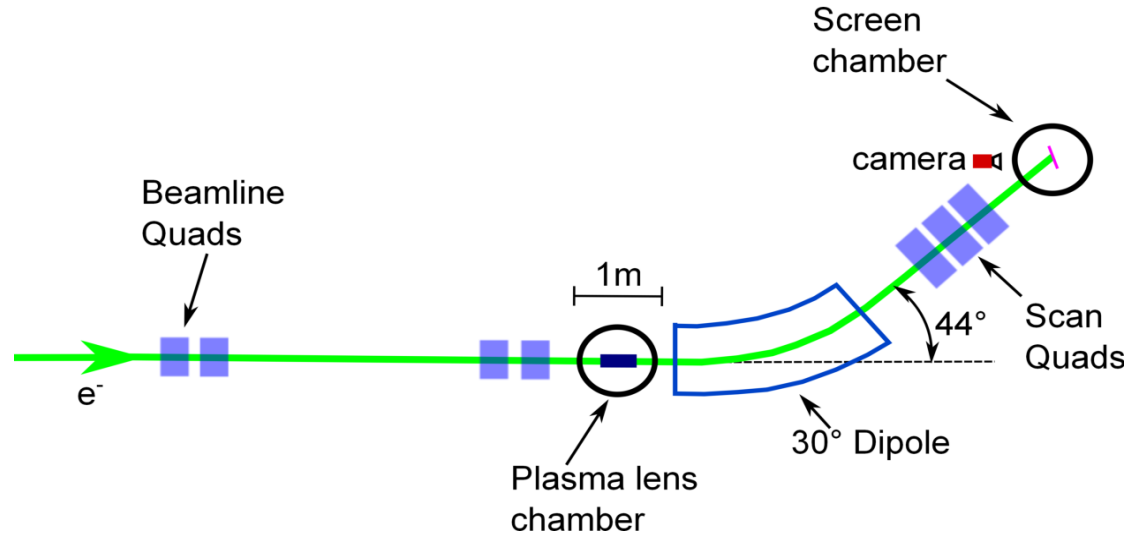
- ▶ First for plasma lens and screen
- ▶ Second for screen

> Large dipole

- ▶ Introduces dispersion
- ▶ Strong edge focusing

> Quadrupole triplet for scan

- ▶ Two independent power supplies
- ▶ Low maximum gradient quads



Emittance scan results

- > Scans using 7 mm long APL
- > rms beam size calculated for 100 shots
- > Resolution of ~ 0.1 mm mrad
- > MaMi-B emittance measured – 1.5 mm mrad
- > Emittance increases in APL

To be published

Current [A]	Normalized emittance [mm mrad]	
	Measured	Simulated
188	2.6 ± 0.2	3.1 ± 1.3
368	3.6 ± 0.2	4.7 ± 1.1
740	9.5 ± 0.1	7.5 ± 1.1

Particle tracking simulations

- > Results from offset scans fed into simulation
- > MaMi-like beam sent through field
- > Emittance for different currents and beam sizes
- > Core emittance can be preserved
- > Small beam size favorable

To be published

Particle tracking simulations

- > Results from offset scans fed into simulation
- > Low emittance beam sent through field
- > Emittance for different currents and beam sizes
- > Core emittance can be preserved in small emittance beams

To be published

FACET II considerations

- > High current beams may drive wake
- > Transversally large beam in APL needed
- > Large beam needs large APL for emittance preservation
- > Drive beam final focus
- > Witness beam capturing

Parameters	Driver	Witness
I_{peak} [kA]	200	15
$\sigma_{x,y}$ [μm]	200	150
n_b [cm^{-3}]	10^{16}	10^{15}
R [mm]	2	2
I_0 [kA]	16	16
g [T/m]	800	800
n_0 [cm^{-3}]	$5 \cdot 10^{16}$	$5 \cdot 10^{16}$
$K_{\text{APL}}/K_{\text{wake}}$	10^5	10^6

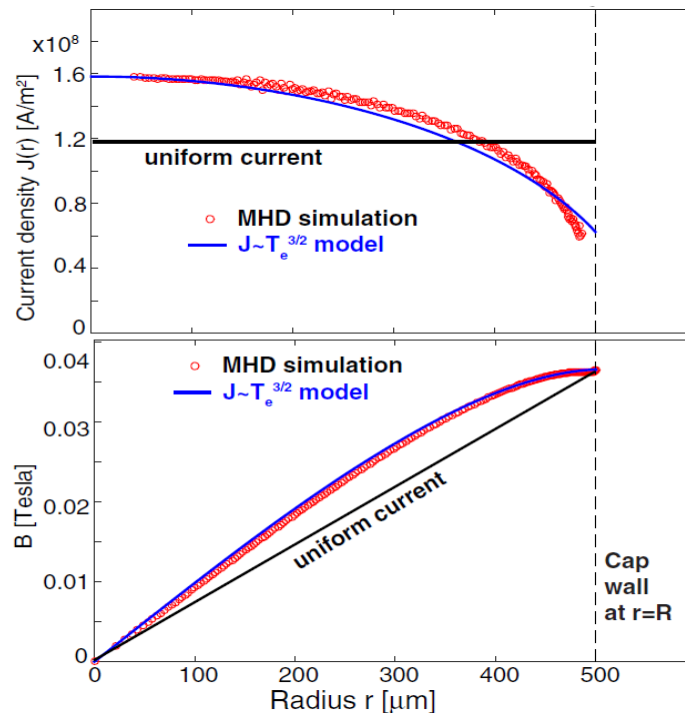
Summary

- > First experiment with a plasma lens in a conventional electron accelerator
- > Direct magnetic field measurement of a capillary plasma lens – 823 T/m over 350 μm
- > Stability of discharge and APL assessed in gradient scans – very stable
- > Study of emittance preservation shows degradation – explained by simulations
- > Emittance preservation possible for relatively small beams
- > Might be a technique worth considering for FACET II program

Thank you for your attention,
please ask away!

APLs – a hot topic

- > Recent publication shows heating effects
- > Heating causes pinching of current
- > Higher focusing field for core part of APL



J. vanTilborg et al., PRAB 20, 032803 (2017)